What is claimed is:

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An optical semiconductor device comprising:
an InP substrate;

a plurality of layers, stacked on the InP substrate, including a multi-quantum well active layer made of InGaAlAs;

an InAlAs electron stopping layer stacked on the plurality of layers;

an InGaAsP layer including a grating stacked on the InAlAs electron stopping layer; and

an InP cladding layer stacked on the InGaAsP layer; wherein a concave depth of the grating included in the InGaAsP layer is smaller than a thickness of the InGaAsP layer.

2. An optical semiconductor device comprising: an InP substrate;

a plurality of layers, stacked on the InP substrate, including a multi-quantum well active layer made of InGaAlAs;

an InAlAs electron stopping layer stacked on the plurality of layers;

an InGaAsP layer including a grating stacked on the InAlAs electron stopping layer;

an InP spacer layer stacked on the InGaAsP layer; an InGaAsP etch stopping layer stacked on the InP

spacer layer; and

an InP cladding layer stacked on the InGaAsP etch stopping layer;

wherein a concave depth of the grating included in the InGaAsP layer is smaller than a thickness of the InGaAsP layer.

- 3. An optical semiconductor device according to claim 2, wherein the spacer layer comprises an InAlAs layer.
- 4. An optical semiconductor device according to claim 1, wherein a composition wavelength of the InGaAsP layer including the grating is not shorter than 1.15 μm and not longer than 1.24 μm .
- 5. An optical semiconductor device according to claim 2, wherein a composition wavelength of the InGaAsP layer including the grating is not shorter than 1.15 μm and not longer than 1.24 μm .
- 6. An optical semiconductor device according to claim 3, wherein a composition wavelength of the InGaAsP layer including the grating is not shorter than 1.15 μ m and not longer than 1.24 μ m.
- 7. An optical semiconductor device according to claim 1, wherein a portion of the InGaAsP layer including the grating consists of a multi-quantum well layer.
- 8. An optical semiconductor device according to claim 2, wherein a portion of the InGaAsP layer including the grating consists of a multi-quantum well layer.

- 9. An optical semiconductor device according to claim 3, wherein a portion of the InGaAsP layer including the grating consists of a multi-quantum well layer.
- 10. An optical semiconductor device according to claim 1, wherein impurity dopants including Si and/or O exist between the InP cladding layer and the InGaAsP layer including the grating.
- 11. An optical semiconductor device according to claim 2, wherein impurity dopants including Si and/or 0 exist between the InP spacer layer and the InGaAsP layer including the grating.
- 12. An optical semiconductor device according to claim 1, wherein the optical semiconductor device is a ridge type laser in which the InP cladding layer has a shape of a ridge mesa stripe.
- 13. An optical semiconductor device according to claim 2, wherein the optical semiconductor device is a ridge type laser in which the InP cladding layer has a shape of a ridge mesa stripe.
- 14. An optical semiconductor device according to claim 1, wherein the optical semiconductor device is a buried type laser.
- 15. An optical semiconductor device according to claim 1, wherein the optical semiconductor device is an integrated light source in which a laser structure and an electro-absorption modulator are integrated.

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- 16. An optical semiconductor device according to claim 2, wherein the optical semiconductor device is an integrated light source in which a laser structure and an electro-absorption modulator are integrated.
- 17. An optical semiconductor device according to claim 13, wherein the optical semiconductor device is an integrated light source in which a laser structure and an electro-absorption modulator are integrated.
- 18. An optical semiconductor device according to claim 14, wherein the optical semiconductor device is an integrated light source in which a laser structure and an electro-absorption modulator are integrated.
- 19. An optical semiconductor device according to claim 1, wherein the optical semiconductor device is an integrated light source in which a laser structure and a Mach-Zender modulator are integrated.
- 20. An optical semiconductor device according to claim 2, wherein the optical semiconductor device is an integrated light source in which a laser structure and a Mach-Zender modulator are integrated.